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Attorney's Docket No.: 42.P5488D6 [042390.P5488D6]

Patent

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:

Chia-Hong Jan, et al.

Application No.: 09/477,764

Filed: January 4, 2000

For: A DEVICE HAVING RECESSED SPACERS
FOR IMPROVED SALICIDE RESISTANCE
ON POLYSILICON GATES

Examiner: Hung K. Vu

Art Unit: 2811

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Assistant Commissioner of Patents
Washington, D.C. 20231-9998

PRELIMINARY AMENDMENT

Dear Sir:

Prior to examination of the above-referenced application, the Applicant respectfully requests the Examiner to enter the following amendments and to consider the following remarks. The Examiner is requested to enter this amendment before calculating the fee.

First-Class Certificate of Mailing

I hereby certify that this correspondence is being deposited with the United States Postal Service as first-class mail with sufficient postage in an envelope addressed to the Assistant Commissioner for Patents, Washington, D.C., 20231 on

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